

Title (en)

COMPOSITION FOR REMOVING CHEMICAL RESIDUES, AND USES THEREOF

Title (de)

ZUSAMMENSETZUNG ZUR ENTFERNUNG VON CHEMISCHEN RÜCKSTÄNDEN UND DEREN VERWENDUNGEN

Title (fr)

COMPOSITION POUR ENLEVER DES RESIDUS CHIMIQUES ET SES UTILISATIONS

Publication

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Application

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Abstract (en)

[origin: WO2020169931A1] The invention relates to a composition for removing chemical residues, a process for producing said composition, and the use of said composition for removing residues from material, machines and equipment soiled by any type of chemical product.

IPC 8 full level

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